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**Shim et al.**

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(54) **MICRO-OPTICAL SWITCHING DEVICE,  
IMAGE DISPLAY APPARATUS INCLUDING  
MICRO-OPTICAL SWITCHING DEVICE,  
AND METHOD OF MANUFACTURING  
MICRO-OPTICAL SWITCHING DEVICE**

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**G02B 26/08** (2006.01)

(52) **U.S. Cl.**

CPC ..... **G02B 26/0841** (2013.01)

(58) **Field of Classification Search**

None

See application file for complete search history.

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(57) **ABSTRACT**

A micro-optical switching device, an image display apparatus including the micro-optical switching device, and a method of manufacturing the micro-optical switching device are provided. The micro-optical switching device includes a substrate; a first electrode disposed on the substrate and including a first opening array, wherein the first opening array includes a plurality of openings; and a second electrode disposed spaced apart from the first electrode and including a second opening array including a plurality of openings, wherein the plurality of openings of the second opening array do not overlap with the plurality of openings of the first opening array.

**23 Claims, 7 Drawing Sheets**

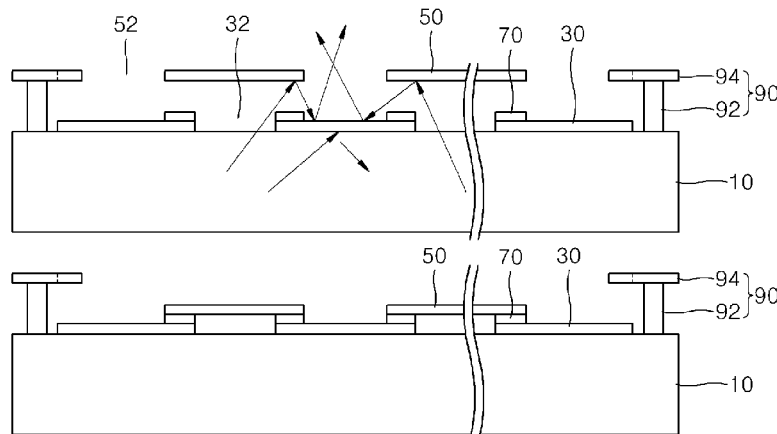


FIG. 1

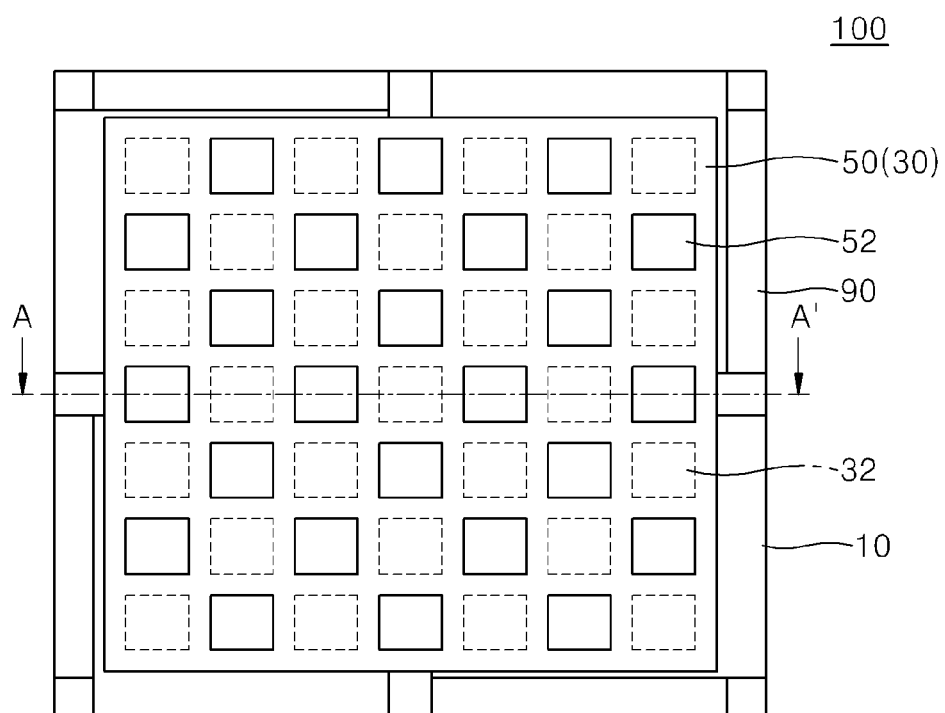


FIG. 2

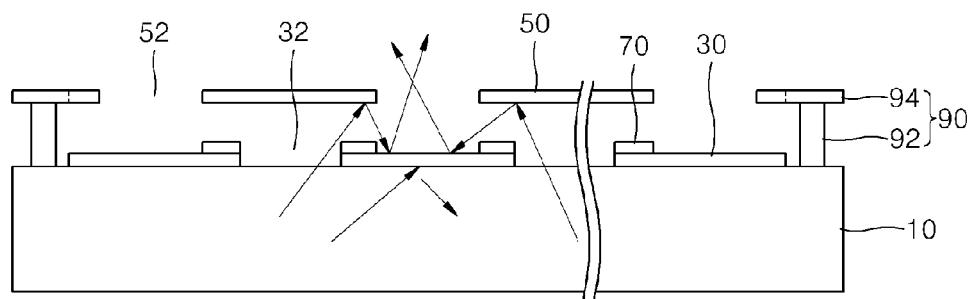


FIG. 3

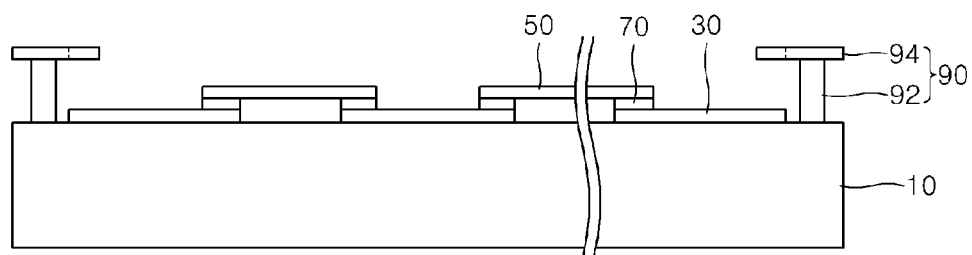


FIG. 4

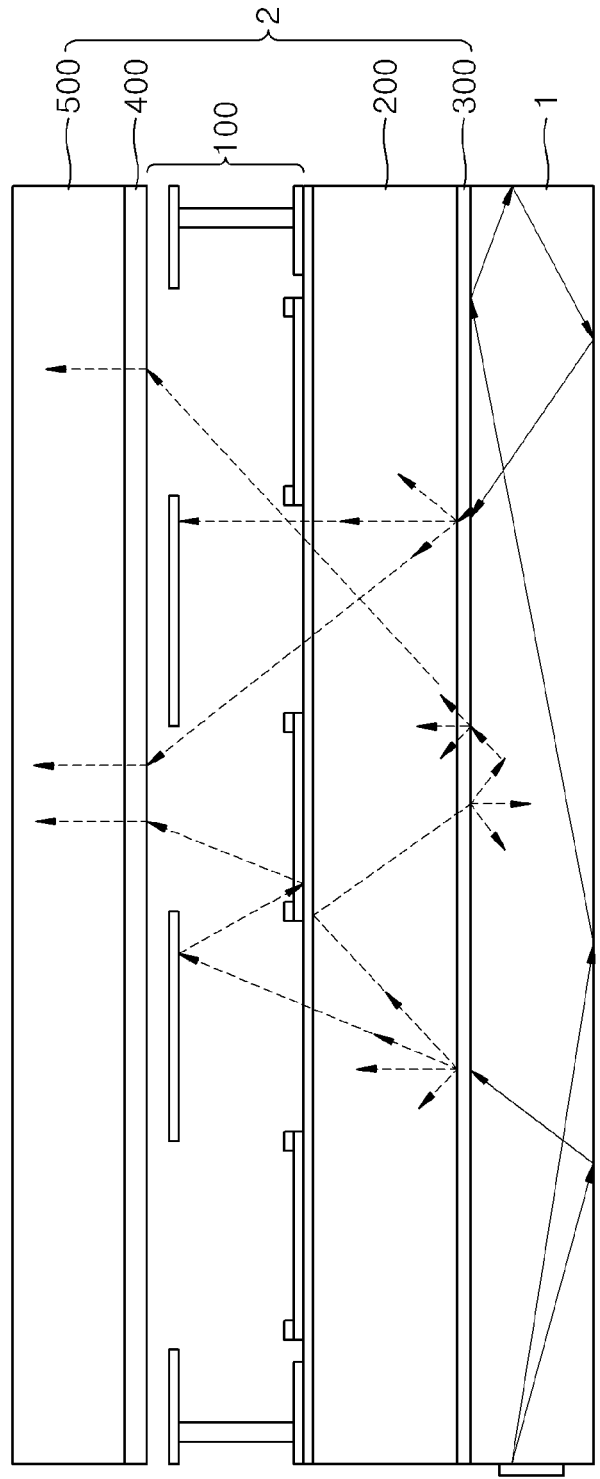


FIG. 5A

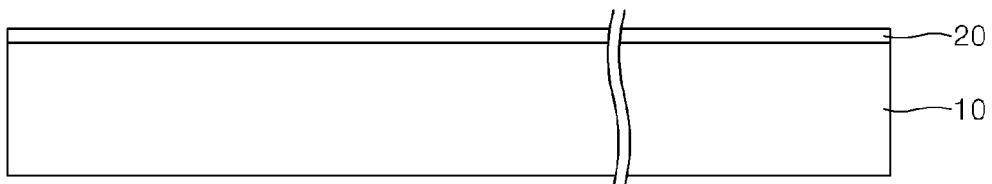


FIG. 5B

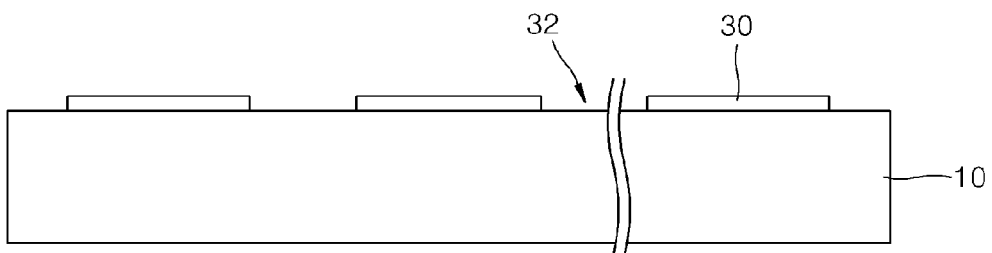


FIG. 5C

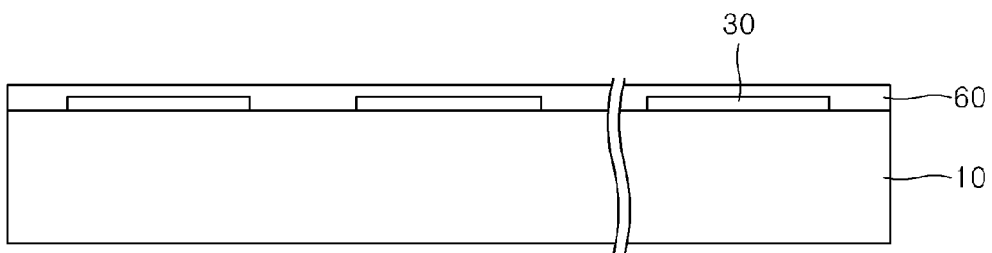


FIG. 5D

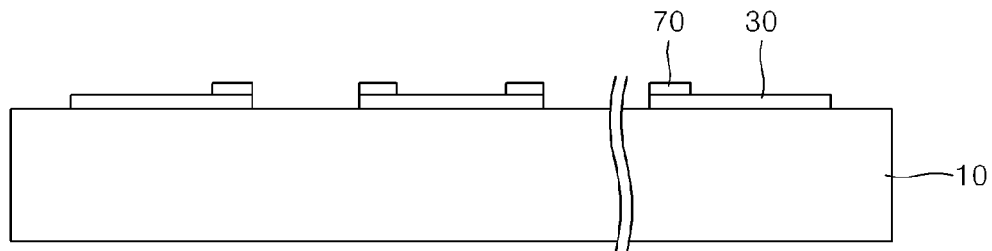


FIG. 5E

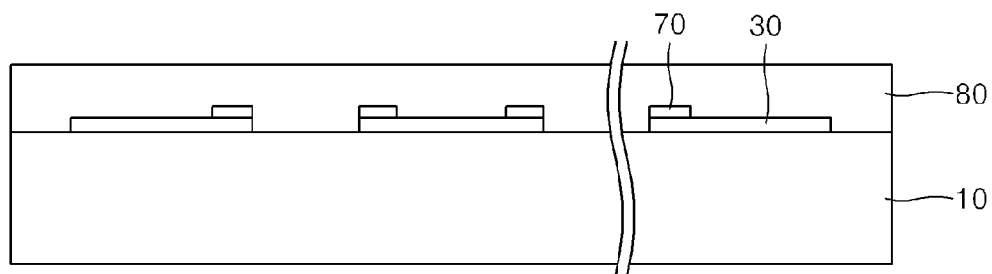


FIG. 5F

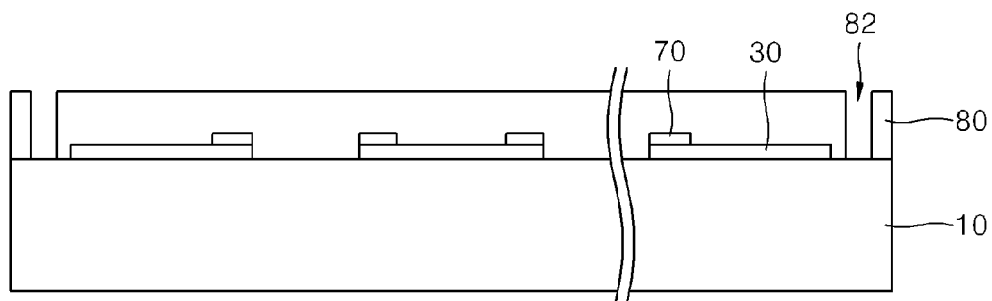


FIG. 5G

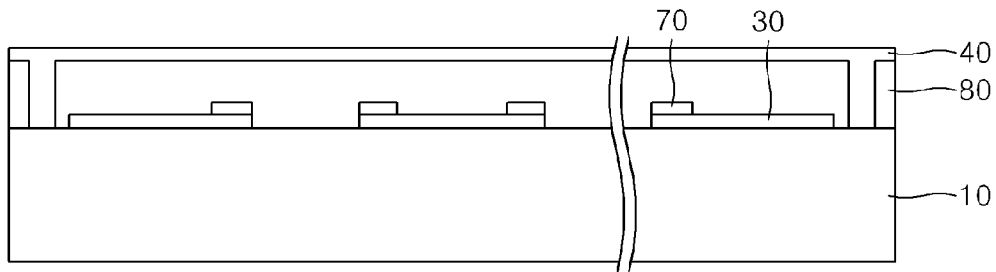


FIG. 5H

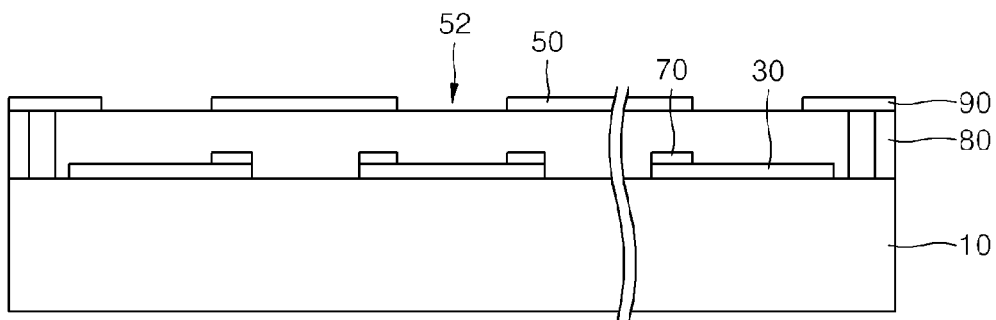


FIG. 5I

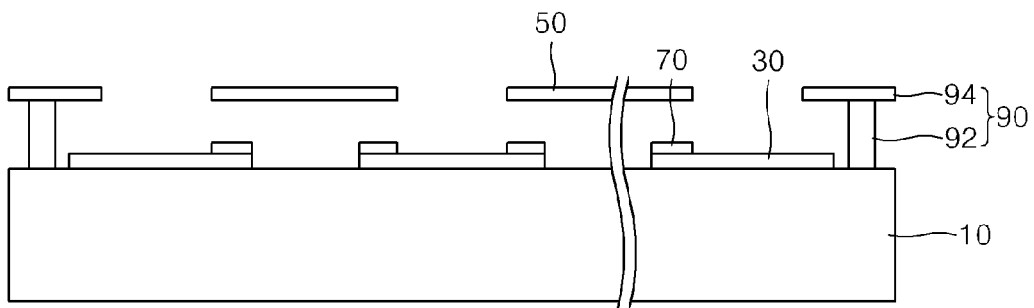


FIG. 6

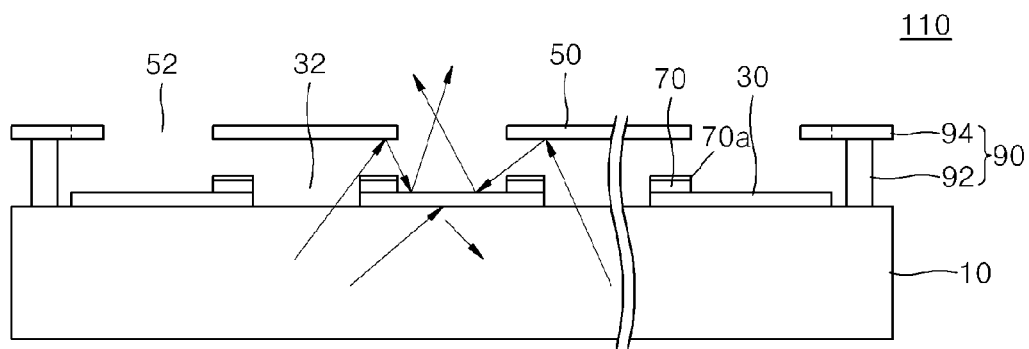
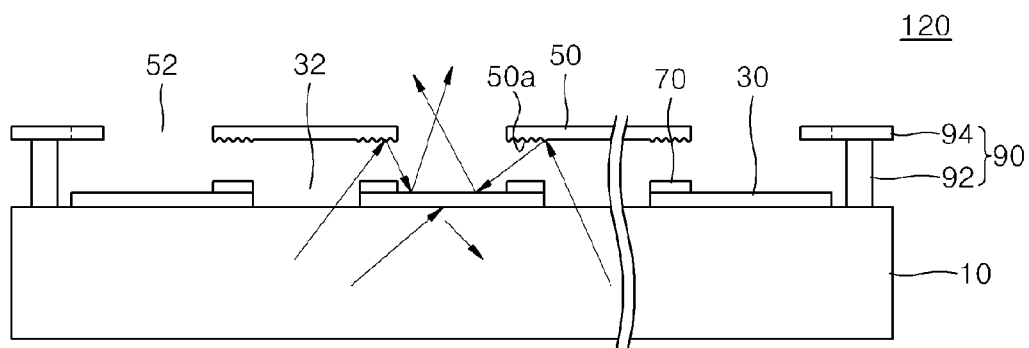


FIG. 7





1

**MICRO-OPTICAL SWITCHING DEVICE,  
IMAGE DISPLAY APPARATUS INCLUDING  
MICRO-OPTICAL SWITCHING DEVICE,  
AND METHOD OF MANUFACTURING  
MICRO-OPTICAL SWITCHING DEVICE**

**CROSS-REFERENCE TO RELATED  
APPLICATION**

This application claims priority from Korean Patent Application No. 10-2011-0093649, filed on Sep. 16, 2011, in the Korean Intellectual Property Office, the disclosure of which is incorporated herein in its entirety by reference.

**BACKGROUND**

**1. Field**

Apparatuses and methods consistent with exemplary embodiments relate to micro-optical switching devices, image display apparatuses including the micro-optical switching devices, and methods of manufacturing the micro-optical switching devices.

**2. Description of the Related Art**

Display apparatuses have been developed from cathode ray tube (CRT) methods that use an existing CRT in flat display apparatuses, such as liquid crystal display (LCD) apparatuses, plasma display panel (PDP) apparatuses, and the like. Display apparatuses that use CRT methods display an image by making electron beams collide with fluorescent materials. As the sizes of display apparatuses that use CRT methods increase, their widths increase greatly, and thus it is not easy to manufacture large display apparatuses. In order to solve this problem, a plurality of flat display apparatuses have been developed.

Although the amount of power consumption of a display panel with respect to the total amount of power consumption of a flat display apparatus increases continuously, the luminescent efficiency of the display panel is very low. In particular, as the sizes of pixels decrease, the luminescent efficiency of the display panel is rapidly lowered.

Thus, micro-optical switching devices for use in display apparatuses with improved luminescent efficiency and simplified manufacturing processes have to be developed.

**SUMMARY**

One or more exemplary embodiments provide micro-optical switching devices with improved luminescent efficiency.

One or more exemplary embodiments provide image display apparatuses with improved luminescent efficiency.

One or more exemplary embodiments provide methods of manufacturing micro-optical switching devices with simplified manufacturing processes.

Additional aspects will be set forth in part in the description which follows and, in part, will be apparent from the description, or may be learned by practice of the presented embodiments.

According to an aspect of an exemplary embodiment, a micro-optical switching device includes: a substrate; a first electrode disposed on the substrate and includes a first opening array including a plurality of openings; and a second electrode disposed spaced apart from the first electrode and includes a second opening array including a plurality of openings, wherein the plurality of openings of the second opening array do not overlap with the plurality of openings of the first opening array.

2

The micro-optical switching device may further include a support member that supports the second electrode in such a way that the second electrode is spaced apart from the first electrode by a predetermined distance.

The support member may include: a first support member that is disposed on the substrate and has a greater thickness than a thickness of the first electrode; and a second support member that is disposed on the first support member and is connected to the second electrode.

The support member may include the same material as that used in forming the second electrode.

The support member may be formed of elastic polymer.

The second electrode may be moved toward or away from the first electrode based on a voltage applied to the micro-optical switching device.

When a voltage is applied to the micro-optical switching device, the second electrode may be moved toward the first electrode, and when no voltage is applied to the micro-optical switching device, the second electrode may be moved away from the first electrode.

Each of the first electrode and the second electrode may include an opaque material.

The first electrode and the second electrode may be coated with a reflective material.

The micro-optical switching device may further include a spacer that is disposed between the first electrode and the second electrode and prevents electrical shorts between the first electrode and the second electrode.

The spacer may be disposed in a region in which the first electrode and the second electrode overlap with each other.

The spacer may be disposed on a top surface of the first electrode or bottom surface of the second electrode.

The spacer may include: a first surface that is disposed on the bottom surface of the second electrode or top surface of the first electrode; and a second surface opposite the first surface and is coated with material that prevents adhesion between the spacer and the first electrode or the second electrode.

A surface of the second electrode or first electrode from which the spacer is detached depending on whether a voltage is applied to the micro-optical switching device may include a rough portion.

Each of the plurality of openings may include at least one of the group consisting of a circular shape, an oval shape, and a polygonal shape.

According to an aspect of another exemplary embodiment, an image display apparatus includes: a backlight unit that emits light; and a display panel that includes a plurality of micro-optical switching devices described above and displays an image by adjusting an amount of light that is transmitted through the display panel from the backlight unit.

The image display apparatus may further include a diffusion plate disposed between the backlight unit and the display panel which diffuses light emitted from the backlight unit.

The display panel may further include an optical film which modifies a path of light that is transmitted through each of the micro-optical switching devices.

According to an aspect of another exemplary embodiment, a method of manufacturing a micro-optical switching device includes: forming a first electrode on a substrate, wherein the first electrode includes a first opening array including a plurality of openings; forming a sacrificial layer covering the first electrode; forming a second electrode on the sacrificial layer, wherein the second electrode includes a second opening array comprising a plurality of openings, wherein the plurality of

3

openings of the second opening array do not overlap with the plurality of openings of the first opening array; and removing the sacrificial layer.

Each of the first electrode and the second electrode may include an opaque conductive material.

The method may further include: removing a portion of the sacrificial layer so that the substrate is exposed to the outside; and forming a support member that supports the second electrode, in a region formed by removing a portion of the sacrificial layer.

The method may further include, before the forming of the first electrode, forming a reflection layer on the substrate, or before the forming of the second electrode, forming a reflection layer on the sacrificial layer.

The method, before the forming of the sacrificial layer, may further include forming an insulating layer between the first electrode and the second electrode.

The insulating layer may be formed in a region in which the first electrode and the second electrode overlap with each other.

The method, after the removing of the sacrificial layer, may further include forming an insulating layer that prevents contact between the first electrode and the second electrode.

#### BRIEF DESCRIPTION OF THE DRAWINGS

These and/or other exemplary aspects and advantages will become apparent and more readily appreciated from the following description of exemplary embodiments, taken in conjunction with the accompanying drawings in which:

FIG. 1 is a plane view of a micro-optical switching device according to an exemplary embodiment;

FIG. 2 is a cross-sectional view of the micro-optical switching device illustrated in FIG. 1 when it is turned off;

FIG. 3 is a cross-sectional view of the micro-optical switching device illustrated in FIG. 1 when it is turned on;

FIG. 4 is a cross-sectional view of an image display apparatus including a micro-optical switching device, according to an exemplary embodiment;

FIGS. 5A through 5I are cross-sectional views illustrating a method of manufacturing a micro-optical switching device, according to an exemplary embodiment;

FIG. 6 is a cross-sectional view of a micro-optical switching device according to another exemplary embodiment; and

FIG. 7 is a cross-sectional view of a micro-optical switching device according to another exemplary embodiment.

#### DETAILED DESCRIPTION

Reference will now be made in detail to embodiments, examples of which are illustrated in the accompanying drawings, wherein like reference numerals refer to like elements throughout. In this regard, the present embodiments may have different forms and should not be construed as being limited to the descriptions set forth herein. Accordingly, the embodiments are merely described below, by referring to the figures, to explain aspects of the present description. Expressions such as “at least one of,” when preceding a list of elements, modify the entire list of elements and do not modify the individual elements of the list.

Exemplary embodiments will now be described more fully with reference to the accompanying drawings.

FIG. 1 is a plane view of a micro-optical switching device 100 according to an exemplary embodiment, and FIG. 2 is a cross-sectional view of the micro-optical switching device 100 illustrated in FIG. 1 when it is turned off, and FIG. 3 is a

4

cross-sectional view of the micro-optical switching device 100 illustrated in FIG. 1 when it is turned on.

As illustrated in FIGS. 1 through 3, the micro-optical switching device 100 may include a lower electrode 30 that is disposed on a substrate 10 and an upper electrode 50 that is disposed spaced apart from the lower electrode 30. The substrate 10 may be formed of a transparent amorphous material through which light may be transmitted, such as glass or the like.

Each of the lower and upper electrodes 30 and 50 may be formed of a conductive material which is not entirely transparent. In detail, the lower and upper electrodes 30 and 50 may be formed of an opaque conductive material with high reflectivity. The lower and upper electrodes 30 and 50 may be formed as a carbon nano-structure formed of carbon nanotube (CNT), graphene, or the like, or may be formed of conductive polymer, such as polypyrrole, polyaniline, polyacetylene, polythiophene, polyphenylene vinylene, polyphenylene sulfide, poly p-phenylene or polyheterocycle vinylene, or metal oxide, such as indium tin oxide (ITO), aluminum zinc oxide (AZO), indium zinc oxide (IZO), tin oxide (SnO<sub>2</sub>), or In<sub>2</sub>O<sub>3</sub>, or may be formed as a metal nano-particle diffusion thin layer formed of at least one metallic material selected from the group consisting of aluminum (Al), copper (Cu), gold (Au), and silver (Ag). The lower and upper electrodes 30 and 50 may also be formed of a colored material, such as a black material, which is non-transparent. Also, bottom surfaces of the lower electrode 30 and the upper electrode 50 may be coated with a reflective material.

The lower electrode 30 may include a first opening array including a plurality of openings 32, and the upper electrode 50 may also include a second opening array including a plurality of openings 52. The first and second opening arrays are disposed so that they do not overlap with each other so that the micro-optical switching device 100 may intercept light or allow light to be transmitted through the first and second opening arrays by moving the upper electrode 50 in an upward or downward direction (away from or closer to the lower electrode). Although FIG. 1 illustrates the openings 32 included in the first opening array and the openings 52 included in the second opening array having a rectangular shape, the present embodiment is not limited thereto. The shapes of the openings 32 and 52 may include at least one of the group consisting of a circular shape, an oval shape, and a polygonal shape. Also, the sizes thereof may be the same or different.

In addition, the micro-optical switching device 100 may further include a spacer 70 that prevents electrical shorts between the lower electrode 30 and the upper electrode 50. The spacer 70 may also be formed of a non-transparent material, for example, the spacer 70 may be formed from at least one insulating material selected from the group consisting of ZrO<sub>2</sub>, TiO<sub>2</sub>, MgO, CeO<sub>2</sub>, Al<sub>2</sub>O<sub>3</sub>, HfO<sub>2</sub>, NbO, SiO<sub>2</sub>, and Si<sub>3</sub>N<sub>4</sub>. The spacer 70 may be disposed between the lower electrode 30 and the upper electrode 50, i.e., in a region in which the lower electrode 30 and the upper electrode 50 overlap with each other. The spacer 70 may be disposed on a top surface of the lower electrode 30, as illustrated in FIGS. 2 and 3. However, the present embodiment is not limited thereto, and the spacer 70 may also be disposed on the bottom surface of the upper electrode 50.

The micro-optical switching device 100 may further include a support member 90 that supports the upper electrode 50 in such a way that the upper electrode 50 is spaced apart from the lower electrode 30 by a predetermined distance. The support member 90 may extend from the upper electrode 50 and may be connected to the substrate 10. For

5

example, the support member **90** may include a first support member **92** that is disposed on the substrate **10** and spaced apart from the lower electrode **30** and a second support member **94** that is disposed on the first support member **92** and extends from the upper electrode **50**. The thickness of the first support member **92** may be determined according to the magnitudes of the voltages that are applied to the lower electrode **30** and the upper electrode **50**. For example, as the magnitudes of the voltages applied to the lower electrode **30** and the upper electrode **50** increase, the thickness of the first support member **92** may be increased. In this regard, the thickness of the first support member **92** may be greater than the sum of the thicknesses of the lower electrode **30** and the spacer **70**. Thus, the upper electrode **50** may be spaced apart from the lower electrode **30** by a predetermined distance due to the support member **90**.

The support member **90** may be disposed outside the lower electrode **30** and the upper electrode **50**, and a plurality of support members **90** may support the upper electrode **50**. When there are a plurality of support members **90**, the plurality of support members **90** may be disposed to be symmetrical with each other about a center of the upper electrode **50**.

The support member **90** may be formed of an elastic material. For example, the support member **90** may be formed of an elastic conductive material or elastic polymer with elasticity. For conveniences of manufacture, the support member **90** may be formed of the same material as that used in forming the upper electrode **50**. However, the present embodiment is not limited thereto, and the support member **90** may be formed of elastic polymer with high elasticity. For example, the support member **90** may be formed of at least one elastic polymer selected from the group consisting of silicon, polysiloxanes, polyurethanes, polysilicon-polyurethanes, rubber, ethylene-vinyl acetate copolymer, phenolic nitrile rubber, styrene butadiene rubber, polyether-block-amides, and polyolefins, or other similar materials to elastic polymer, such as various types of gels.

The micro-optical switching device **100** operates as described below depending on whether a voltage is applied thereto.

When no voltage is applied to the micro-optical switching device **100**, the upper electrode **50** of the micro-optical switching device **100** may be spaced apart from the lower electrode **30** due to an intrinsic elastic force of the support member **90**, as illustrated in FIG. 2. Thus, light that is incident on the substrate **10** is emitted through the first opening array of the lower electrode **30** and the second opening array of the upper electrode **50** to the outside. In this case, the first and second opening arrays do not overlap with each other. Thus, some incident light may be directly transmitted through the first and second opening arrays or may be reflected by the lower electrode **30** or the upper electrode **50** and thus may be emitted to the outside.

However, when a voltage is applied to the micro-optical switching device **100**, the upper electrode **50** of the micro-optical switching device **100** is moved in a downward direction and is disposed on the spacer **70**, and the support member **90** may expand due to the movement of the upper electrode **50**. Since the first and second opening arrays do not overlap with each other, light that is incident on the substrate **10** is reflected by the lower electrode **30** and the upper electrode **50** and thus is not transmitted through the first and second opening arrays.

Also, when the voltage applied to the micro-optical switching device **100** stops, the support member **90** may be restored to its original state. In this manner, depending on whether a

6

voltage is applied to the micro-optical switching device **100**, the upper electrode **50** may be moved in the upward or downward direction so that the light that is incident on the substrate **10** may be transmitted through the first and second opening arrays or may be intercepted.

Although, in FIGS. 2 and 3, the light that is incident on the substrate **10** is transmitted through the first and second opening arrays or is intercepted due to the upward or downward direction of the upper electrode **50**, the present embodiment is not limited thereto. Since the spacing between the upper electrode **50** and the lower electrode **30** may be adjusted according to the magnitude of the voltage applied to the micro-optical switching device **100**, the amount of light transmitted through the first and second opening arrays may also be adjusted.

The micro-optical switching device **100** may be an element of a display panel **2** (see FIG. 4) that displays an image by intercepting light or allowing light to be transmitted through the display panel **2**.

FIG. 4 is a cross-sectional view of an image display apparatus including a plurality of micro-optical switching devices **100**, according to an exemplary embodiment. Referring to FIG. 4, the image display apparatus includes a display panel **2** that includes the plurality of micro-optical switching devices **100** and is surrounded by a lower display plate **200** and an upper display plate **500** and a backlight unit **1** that is disposed under the display panel **2**.

The backlight unit **1** may include a light source and a light guide panel (LGP) that are elements for providing light to the display panel **2**. The display panel **2** may further include a diffusion plate **300** that diffuses light emitted from the backlight unit **1**.

The display panel **2** may display an image by intercepting light that is emitted from the backlight unit **1** or by allowing the light to be transmitted through the display panel **2**. The display panel **2** adjusts the amount of transmitted light by using the micro-optical switching devices **100**.

The display panel **2** is surrounded by the lower display plate **200** and the upper display plate **500**. The upper display plate **500** and the lower display plate **200** are formed of glass or the like and allow light to be transmitted therethrough. The micro-optical switching devices **100**, and an optical film **400**, may be disposed between the lower display plate **200** and the upper display plate **500**.

One of the micro-optical switching devices **100** may be disposed in each pixel. Various voltages may be applied to the micro-optical switching devices **100**, and the amount of light that is transmitted through the first and second opening arrays when the upper electrode **50** is moved in the upward or downward direction is adjusted according to the voltages applied to the micro-optical switching devices **100**.

Although light that is emitted from the backlight unit **1** may be transmitted through the micro-optical switching devices **100** through the first opening array of the lower electrode **30** and the second opening array of the upper electrode **50**, some light may be reflected from the lower electrode **30** or the upper electrode **50**. The reflected light is incident on the backlight unit **1**, is re-reflected from the backlight unit **1** and is incident again on the micro-optical switching devices **100** and is reused. Since light that is not transmitted through the micro-optical switching devices **100** is re-reflected from the backlight unit **1** and is incident on the micro-optical switching devices **100**, as described above, power consumption of the image display apparatus may be reduced and luminescent efficiency thereof may be improved by using the micro-optical switching devices **100**.

The optical film **400** is used to modify a path of light that is incident from the micro-optical switching devices **100** so as to make the light incident on the upper display plate **500**. The optical film **400** may be a prism, a diffusion plate, a polarization plate, or the like.

Although not shown, wirings for applying signals to the micro-optical switching devices **100** may be disposed on the lower display plate **200** or the upper display plate **500**.

In addition, the upper display plate **500** may include a black matrix and color filters. The black matrix may be used to prevent light, other than light that is used in displaying an image, from proceeding in the upward direction. The color filters are disposed in units of pixels that are units for displaying an image, and the black matrix is disposed between the color filters so as to distinguish the pixels. The color filters are used to add a sense of color to the light that is emitted from the backlight unit **1** and may generally be red, green, and blue color filters.

Hereinafter, a method of manufacturing the micro-optical switching device **100**, according to an exemplary embodiment, will be described.

FIGS. **5A** through **5I** are cross-sectional views illustrating a method of manufacturing the micro-optical switching device **100**, according to an exemplary embodiment.

First, referring to FIG. **5A**, a first conductive material layer **20** with a light-intercepting property is formed on a transparent substrate **10**. The first conductive material layer **20** may be formed of an opaque conductive material with low light transmittance and high reflectivity. For example, the first conductive material layer **20** may be formed as a carbon nanostructure formed of CNT, graphene, or the like or is formed of conductive polymer, such as polypyrrole, polyaniline, polyacetylene, polythiophene, polyphenylene vinylene, polyphenylene sulfide, poly p-phenylene or polyheterocycle vinylene, or metal oxide, such as indium tin oxide (ITO), aluminum zinc oxide (AZO), indium zinc oxide (IZO), tin oxide (SnO<sub>2</sub>), or In<sub>2</sub>O<sub>3</sub>, or is formed as a metal nano-particle diffusion thin layer formed of at least one metallic material selected from the group consisting of aluminum (Al), copper (Cu), gold (Au), and silver (Ag) may be formed on the transparent substrate **10**.

Referring to FIG. **5B**, the first conductive material layer **20** is patterned, thereby forming a lower electrode **30** including a first opening array including a plurality of openings **32**. Then, referring to FIG. **5C**, an insulating layer **60** is formed on the lower electrode **30** and the transparent substrate **10**. The insulating layer **60** may be formed of a non-transparent material, for example, an opaque material which may be at least one insulating material selected from the group consisting of ZrO<sub>2</sub>, TiO<sub>2</sub>, MgO, CeO<sub>2</sub>, Al<sub>2</sub>O<sub>3</sub>, HfO<sub>2</sub>, NbO, SiO<sub>2</sub>, and Si<sub>3</sub>N<sub>4</sub>. Next, referring to FIG. **5D**, the insulating layer **60** is patterned, thereby forming a spacer **70** on a portion of the top surface of the lower electrode **30**. The spacer **70** may be formed on the entire top surface of the lower electrode **30** or in a portion of the top surface of the lower electrode **30**.

Referring to FIG. **5E**, a sacrificial layer **80** that covers the lower electrode **30** and the spacer **70** is formed on the transparent substrate **10**. The sacrificial layer **80** may be formed of a photosensitive material, for example, a solvent that is volatilized from a solid powder that chemically reacts with light. Then, referring to FIG. **5F**, the sacrificial layer **80** is patterned, thereby forming an opening **82** for exposing a portion of the transparent substrate **10**. The opening **82** is formed outside the lower electrode **30** and may be distanced therefrom.

Referring to FIG. **5G**, a second conductive material layer **40** that covers the sacrificial layer **80** is formed on the transparent substrate **10**. The second conductive material layer **40**

may be the same as the first conductive material layer **20** or different therefrom. The second conductive material layer **40** may be formed of a conductive material with elasticity. In addition, the second conductive material layer **40** is patterned, thereby forming an upper electrode **50** and a support member **90**, as illustrated in FIG. **5H**. A central portion of the second conductive material layer **40** is patterned in such a way that a second opening array including a plurality of openings **52** is formed not to overlap with the first opening array, thereby forming the upper electrode **50**. In addition, when the upper electrode **50** is formed, the central portion of the second conductive material layer **40** is patterned in such a way that the spacer **70** is disposed between the second conductive material layer **40** of the upper electrode **50** and the first conductive material layer **20** of the lower electrode **30**. Then, the remaining portion of the second conductive material layer **40** is patterned to form the support member **90**. The support member **90** is formed by patterning edge portions of the second conductive material layer **40**. The edge portions of the second conductive material layer **40** include a portion of the second conductive material layer **40** formed in the opening **82**. The portion of the second conductive material layer **40** formed in the opening **82** may be a first support member **92**, and an upper portion of the opening **82** and a portion of the second conductive material layer **40** that is disposed at a perimeter of the opening **82** may be a second support member **94**.

Last, the sacrificial layer **80** is removed, as illustrated in FIG. **5I**. For example, the sacrificial layer **80** may be removed in an etching process.

In the current embodiment, the spacer **70** is formed after the lower electrode **30** is formed. However, the present embodiment is not limited thereto. The spacer **70** may also be formed on a top surface of the lower electrode **30** or a bottom surface of the upper electrode **50** after the sacrificial layer **80** is removed. Also, in the current embodiment, the support member **90** is formed from the second conductive material layer **40** that is formed of the same material as that used in forming the upper electrode **50**. However, the present embodiment is not limited thereto. The support member **90** may be formed of material that is different from material used in forming the second conductive material layer **40**, for example, elastic polymer. In this way, when the support member **90** is formed of material that is different from material used in forming the upper electrode **50**, the upper electrode **50** may be formed after the support member **90** is formed, or the support member **90** may be formed after the upper electrode **50** is formed.

The upper electrode **50** of the micro-optical switching device **100** is detached from the spacer **70** depending on whether a voltage is applied to the micro-optical switching device **100**. Thus, an adhesion-preventing material may be coated between the upper electrode **50** and the spacer **70**, or an unevenness portion may be formed on the bottom surface of the upper electrode **50** so that the spacer **70** and the upper electrode **50** may easily detach from each other.

FIG. **6** is a cross-sectional view of a micro-optical switching device **110** according to another exemplary embodiment, and FIG. **7** is a cross-sectional view of a micro-optical switching device **120** according to another exemplary embodiment.

Referring to FIG. **6**, when a bottom surface of a spacer **70** is disposed on a top surface of a lower electrode **30**, a material layer **70a** that prevents adhesion between the spacer **70** and the upper electrode **50** may be formed on a top surface of the spacer **70**. Although, in FIG. **6**, the material layer **70a** that prevents adhesion between the spacer **70** and the upper electrode **50** is disposed on the spacer **70**, the present embodiment

is not limited thereto. For example, the material layer **70a** may be disposed on a bottom surface of an upper electrode **50**. Alternatively, if the spacer **70** is disposed on the bottom surface of the upper electrode **50**, the material layer **70a** may be disposed on the bottom surface of the spacer **70** or the top surface of the lower electrode **30**.

In addition, referring to FIG. 7, an unevenness portion **50a** that minimizes a contact area between the spacer **70** and the upper electrode **50** may be formed on the upper electrode **50** of the micro-optical switching device **120**. The unevenness portion **50a** may be formed on the entire bottom surface of the upper electrode **50** or in a portion of the bottom surface of the upper electrode **50** that corresponds to the spacer **70**. Alternatively, the unevenness portion **50a** may be formed on the top surface of the spacer **70**. Alternatively, if the spacer **70** is disposed on the bottom surface of the upper electrode **50**, the unevenness portion **50a** may be formed on the bottom surface of the spacer **70** or the upper surface of the lower electrode **30**.

As described above, according to the one or more of the above embodiments, a micro-optical switching device may adjust the amount of transmitted light according to the upward or downward movement of an electrode.

In addition, light that is not transmitted through the micro-optical switching device is re-reflected and is incident so that luminescent efficiency of the micro-optical switching device may be improved.

In addition, since luminescent efficiency of the micro-optical switching device is improved, an image display apparatus that reduces power consumption may be provided.

Furthermore, the micro-optical switching device may be provided by using a simplified manufacturing process.

It should be understood that the exemplary embodiments described therein should be considered in a descriptive sense only and not for purposes of limitation. Descriptions of features or aspects within each embodiment should typically be considered as available for other similar features or aspects in other embodiments.

What is claimed is:

1. A micro-optical switching device comprising:
  - a substrate;
  - a first electrode disposed on the substrate and comprising a first opening array which comprises a plurality of openings;
  - a second electrode spaced apart from the first electrode and comprising a second opening array which comprises a plurality of openings, wherein the plurality of openings of the second opening array do not overlap with the plurality of openings of the first opening array; and
  - a spacer disposed in a region in which the first electrode and the second electrode overlap with each other, wherein the second electrode is configured to move in a direction perpendicular to a plane of the first electrode based on a voltage applied to the micro-optical switching device, such that, in a closed position, the second electrode and the first electrode contact the spacer, thereby blocking light from passing between the first electrode and the second electrode, and in an open position, one of the second electrode and the first electrode detaches from the spacer, thereby allowing light to pass between the first electrode and the second electrode.
2. The micro-optical switching device of claim 1, further comprising a support member that supports the second electrode in such a way that the second electrode is spaced apart from the first electrode by a predetermined distance.
3. The micro-optical switching device of claim 2, wherein the support member comprises:

- a first support member that is disposed on the substrate and has a greater thickness than a thickness of the first electrode; and
  - a second support member that is disposed on the first support member and is connected to the second electrode.
4. The micro-optical switching device of claim 2, wherein the support member comprises a material which is the same as a material used in forming the second electrode.
  5. The micro-optical switching device of claim 2, wherein the support member is formed of elastic polymer.
  6. The micro-optical switching device of claim 1, wherein the second electrode is adjustable toward and away from the first electrode based on the voltage is applied to the micro-optical switching device.
  7. The micro-optical switching device of claim 1, wherein, when a voltage is applied to the micro-optical switching device, the second electrode is moved in a downward direction such that the second electrode contacts the first electrode, and when no voltage is applied to the micro-optical switching device, the second electrode is moved in an upward direction such that the second electrode is separated from the first electrode.
  8. The micro-optical switching device of claim 1, wherein each of the first electrode and the second electrode comprises an opaque material.
  9. The micro-optical switching device of claim 1, wherein the first electrode and the second electrode are each coated with a reflective material.
  10. The micro-optical switching device of claim 1, wherein the prevents electrical shorts between the first electrode and the second electrode.
  11. The micro-optical switching device of claim 10, wherein the spacer is disposed on a top surface of the first electrode or bottom surface of the second electrode.
  12. The micro-optical switching device of claim 10, wherein the spacer comprises:
    - a first surface that is disposed on the bottom surface of the second electrode or top surface of the first electrode; and
    - a second surface opposite the first surface which is coated with material that prevents adhesion between the spacer and the first electrode or the second electrode.
  13. The micro-optical switching device of claim 10, wherein a surface of the second electrode or first electrode from which the spacer is detachable depending on whether a voltage is applied to the micro-optical switching device comprises a rough portion.
  14. The micro-optical switching device of claim 1, wherein each of the plurality of openings comprises at least one of the group consisting of a circular shape, an oval shape, and a polygonal shape.
  15. An image display apparatus comprising:
    - a backlight unit that emits light; and
    - a display panel comprising a plurality of micro-optical switching devices of claim 1, wherein the display panel displays an image by adjusting an amount of light transmitted through the display panel from the backlight unit.
  16. The image display apparatus of claim 15, further comprising a diffusion plate disposed between the backlight unit and the display panel which diffuses light emitted from the backlight unit.
  17. The image display apparatus of claim 15, wherein the display panel further comprises an optical film which modifies a path of light that is transmitted through each of the micro-optical switching devices.
  18. A method of manufacturing a micro-optical switching device, the method comprising:

## 11

forming a first electrode on a substrate, wherein the first electrode comprises a first opening array comprising a plurality of openings;  
 forming a spacer on the first electrode;  
 forming a sacrificial layer covering the first electrode and the spacer;  
 forming a second electrode on the sacrificial layer, wherein the second electrode comprises a second opening array comprising a plurality of openings, wherein the plurality of openings of the second opening array does not overlap with the plurality of openings of the first opening array; and  
 removing the sacrificial layer;  
 wherein the spacer is disposed in a region in which the first electrode and the second electrode overlap with each other, and the second electrode is configured to move in a direction perpendicular to a plane of the first electrode based on a voltage applied to the micro-optical switching device, such that, in a closed position, the second electrode and the first electrode contact the spacer, thereby blocking light from passing between the first electrode and the second electrode, and in an open position, one of the second electrode and the first electrode

## 12

detaches from the spacer, thereby allowing light to pass between the first electrode and the second electrode.

19. The method of claim 18, wherein each of the first electrode and the second electrode comprises an opaque conductive material.

20. The method of claim 18, further comprising:  
 removing a portion of the sacrificial layer so that the substrate is exposed to the outside; and  
 forming a support member that supports the second electrode, in a region formed by removing a portion of the sacrificial layer.

21. The method of claim 18, further comprising, before the forming of the first electrode, forming a reflection layer on the substrate, or before the forming of the second electrode, forming a reflection layer on the sacrificial layer.

22. The method of claim 18, wherein the forming the spacer comprises  
 forming an insulating layer on the first electrode.

23. The method of claim 18, after the removing of the sacrificial layer, further comprising forming an insulating layer that prevents contact between the first electrode and the second electrode.

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